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ATTORNEY DOCKET NO. FIRST NAMED INVENTOR FILING DATE APPLICATION NO. PNET.009D/ AMILAY 01/25/01 09/768,271

MMC2/1012

EXAMINER

JONES & VOLENTINE, L.L.P. SUITE 150 12200 SUNRISE VALLEY DRIVE RESTON VA 20191

MAI,A PAPER NUMBER ART UNIT 2814

DATE MAILED:

10/12/01

Please find below and/or attached an Office communication concerning this application or proceeding.

Commissioner of Patents and Trademarks

	Application No.	Applicant(s)
,	09/768,271	YAJIMA, TSUKASA
Office Action Summary	Examiner	Art Unit
	Anh D. Mai	2814
The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply		
A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely. - If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication. - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). - Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b). Status		
1) Responsive to communication(s) filed on 25.	lanuary 2001 .	
2a) ☐ This action is FINAL . 2b) ☑ Th	is action is non-final.	
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.		
Disposition of Claims		
4) Claim(s) 4-10 is/are pending in the application.		
4a) Of the above claim(s) is/are withdrawn from consideration.		
5) Claim(s) is/are allowed.		
6)⊠ Claim(s) <u>4-10</u> is/are rejected.		
7) Claim(s) is/are objected to.		
8) Claim(s) are subject to restriction and/or election requirement.		
Application Papers		
9)☐ The specification is objected to by the Examiner.		
10)⊠ The drawing(s) filed on <u>25 January 2001</u> is/are: a)⊠ accepted or b) objected to by the Examiner.		
Applicant may not request that any objection to the	e drawing(s) be held in abeyance. Se	ee 37 CFR 1.85(a).
11) ☐ The proposed drawing correction filed on is: a) ☐ approved b) ☐ disapproved by the Examiner.		
If approved, corrected drawings are required in reply to this Office action.		
12)☐ The oath or declaration is objected to by the Examiner.		
Priority under 35 U.S.C. §§ 119 and 120		
13)⊠ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).		
a)⊠ All b)☐ Some * c)☐ None of:		
1. Certified copies of the priority documents have been received.		
2. Certified copies of the priority documents have been received in Application No. 09/038,749.		
 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. 		
14) Acknowledgment is made of a claim for domestic priority under 35 U.S.C. § 119(e) (to a provisional application).		
a) ☐ The translation of the foreign language provisional application has been received. 15)☐ Acknowledgment is made of a claim for domestic priority under 35 U.S.C. §§ 120 and/or 121.		
Attachment(s)		
 Notice of References Cited (PTO-892) Notice of Draftsperson's Patent Drawing Review (PTO-948) Information Disclosure Statement(s) (PTO-1449) Paper No(s) 	· <u> </u>	(PTO-413) Paper No(s) Patent Application (PTO-152) .

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DETAILED ACTION

Claim Rejections - 35 USC § 112

The following is a quotation of the second paragraph of 35 U.S.C. 112: 1.

The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.

Claims 4 and 5 rejected under 35 U.S.C. 112, second paragraph, as being incomplete for 2. omitting essential structural cooperative relationships of elements, such omission amounting to a gap between the necessary structural connections. See MPEP § 2172.01. The omitted structural cooperative relationships are: "which a silicon nitride layer is selectively <u>removed</u>".

Where is the silicon nitride with respect to the "layer" and the field oxide?

Insofar as the final structure is concerned, the silicon nitride layer is no longer existed, thus the semiconductor device comprises a field oxide and a layer formed on the surface of the field oxide.

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- Claims 4 and 5 are rejected under 35 U.S.C. 102(b) as being clearly anticipated by Seeds 3. et al. (U.S. Patent No. 3,913,211).

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As best understood by the examiner, Seeds teaches semiconductor device as claimed including:

a field oxide (16a) for device isolation; and

a layer (17) formed on the surface of the field oxide, the layer (17) being composed of a selective removable material. (See Fig. 1e).

Product by process limitation:

The expression "such as to establish a condition under which a silicon nitride layer is selectively removed" is taken to be a product by process limitation and is given no patentable weight. A product by process claim directed to the product per se, no matter how actually made, *In re Hirao*, 190 USPQ 15 at 17 (footnote 3). See *In re Fessman*, 180 USPQ 324, 326 (CCPA 1974); *In re Marosi et al.*, 218 USPQ 289, 292 (Fed. Cir. 1983); and particularly *In re Thorpe*, 227 USPQ 964, 966 (Fed. Cir. 1985), all of which make it clear that it is the patentability of the final structure of the product "gleaned" from the process steps, which must be determined in a "product by process" claim, and not the patentability of the process. See also MPEP 2113.

Moreover, an old and obvious product produced by a new method is not a patentable product, whether claimed in "product by process" claims or not.

- With respect to claim 5, the selective removable material of Seeds is polysilicon.
- 4. Claims 6-10 are rejected under 35 U.S.C. 102(b) as being clearly anticipated by Seeds '211.

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Seeds teaches a semiconductor device as claimed including:

a gate formed on an active region of a substrate (11);

a field oxide (16a) formed on the substrate adjacent the active region;

a protective layer (17d) formed on the field oxide, the protective layer being a material different than the field oxide;

an insulating layer (20) formed on the substrate including the gate (17a), the field oxide (16a) and the protective layer;

a contact hole (20a) formed through the insulating layer (20); and a connecting wire (21) coupled to the gate through the contact hole. (See Fig. 1h).

With respect to claim 7, the protective layer (17a) of Seeds is a polysilicon layer.

With respect to claim 8, it appears that the protective layer (17a) of Seeds is formed on the field oxide only.

With respect to claim 9, the gate of Seeds is a MOSFET gate.

With respect to claim 10, the gate of Seeds further comprises side walls and the side walls being covered by the insulating layer (20).

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Anh D. Mai whose telephone number is (703) 305-0575. The examiner can normally be reached on 8:30AM-5:00PM.

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If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Olik Chaudhuri can be reached on (703) 306-2794. The fax phone numbers for the organization where this application or proceeding is assigned are (703) 308-7722 for regular communications and (703) 308-7722 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 308-0956.

A.M October 9, 2001

> OLIK CHAUDHURI SUPERVISORY PATENT EXAMINER TECHNOLOGY CENTER 2800